## **ELECTRONIC INFORMATION DISCLOSURE STATEMENT**

## **Electronic Version v18**

Stylesheet Version v18.0

Title of Invention

LOW-K INTERLEVEL DIELECTRIC LAYER (ILD) AND METHOD

**Application Number:** 

**Confirmation Number:** 

First Named Applicant:

Matthew Angyal

Attorney Docket Number:

FIS920040049US1

Art Unit:

Examiner:

Search string:

(6528432 or 6436808 or 6483173).pn

## **US Patent Documents**

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

| init | Cite.No. | Patent No. | Date       | Patentee    | Kind     | Class | Subclass |
|------|----------|------------|------------|-------------|----------|-------|----------|
| an   | 1        | 6528432    | 2003-03-04 | Ngo, et al. | -        |       |          |
| a    | 2        | 6436808    | 2002-08-20 | Ngo, et al. | Ĵ        |       | (        |
| a    | 3        | 6483173    | 2002-11-19 | Li, et al.  | <u> </u> |       |          |

## **Signature**

| Examiner Name | Date     |
|---------------|----------|
| and Muya      | 08/02/05 |